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APPLICATION NO.	FILING DATE	FIRST NAMED INVENTOR	ATTORNEY DOCKET NO.	CONFIRMATION NO.	
10/809,409	03/26/2004	Toru Tojo .	251154US2SRDX	7571	
22850	7590 11/15/2006		EXAMINER		
C. IRVIN MCCLELLAND			AKANBI, ISIAKA O		
OBLON, SPIVAK, MCCLELLAND, MAIER & NEUSTADT, P.C.					
1940 DUKE			ART UNIT	PAPER NUMBER	
ALEXANDR	JA, VA 22314		2877		

DATE MAILED: 11/15/2006

Please find below and/or attached an Office communication concerning this application or proceeding.

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·	Application No.	Applicant(s)				
Office Action Surrey	10/809,409	TOJO ET AL.				
Office Action Summary	Examiner	Art Unit				
	Isiaka O. Akanbi	2877				
The MAILING DATE of this communication Period for Reply	n appears on the cover sheet w	th the correspondence address				
A SHORTENED STATUTORY PERIOD FOR RI WHICHEVER IS LONGER, FROM THE MAILIN - Extensions of time may be available under the provisions of 37 CI after SIX (6) MONTHS from the mailing date of this communication. If NO period for reply is specified above, the maximum statutory period for reply within the set or extended period for reply will, by sexually received by the Office later than three months after the earned patent term adjustment. See 37 CFR 1.704(b).	IG DATE OF THIS COMMUNI: FR 1.136(a). In no event, however, may a in. period will apply and will expire SIX (6) MON statute, cause the application to become Al	CATION. reply be timely filed ITHS from the mailing date of this communication. BANDONED (35 U.S.C. 8 133)				
Status						
1) Responsive to communication(s) filed on 3	30 August 2006.					
	This action is non-final.					
3) Since this application is in condition for all	owance except for formal matt	ers, prosecution as to the merits is				
closed in accordance with the practice und						
Disposition of Claims						
4) ☐ Claim(s) 1-21 is/are pending in the application. 4a) Of the above claim(s) is/are withdrawn from consideration. 5) ☐ Claim(s) 17-21 is/are allowed. 6) ☐ Claim(s) 1-3,6-11,14-15 and 16 is/are rejected. 7) ☐ Claim(s) 4,5,12 and 13 is/are objected to. 8) ☐ Claim(s) are subject to restriction and/or election requirement.						
Application Papers						
9) The specification is objected to by the Exar 10) The drawing(s) filed on 26 March 2004 is/a Applicant may not request that any objection to Replacement drawing sheet(s) including the co	re: a) \boxtimes accepted or b) \square objointh the drawing(s) be held in abeyare or rection is required if the drawing	ice. See 37 CFR 1.85(a). (s) is objected to. See 37 CFR 1.121(d).				
Priority under 35 U.S.C. § 119						
 12) Acknowledgment is made of a claim for foreign priority under 35 U.S.C. § 119(a)-(d) or (f). a) All b) Some * c) None of: 1. Certified copies of the priority documents have been received. 2. Certified copies of the priority documents have been received in Application No 3. Copies of the certified copies of the priority documents have been received in this National Stage application from the International Bureau (PCT Rule 17.2(a)). * See the attached detailed Office action for a list of the certified copies not received. 						
Attachment(s)						
1) Notice of References Cited (PTO-892) 2) Notice of Draftsperson's Patent Drawing Review (PTO-948 3) Information Disclosure Statement(s) (PTO-1449 or PTO/SE Paper No(s)/Mail Date) Paper No(s	tummary (PTO-413))/Mail Date Iformal Patent Application (PTO-152) 				

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DETAILED ACTION

Amendment

The amendment file 30 August 2006 has been entered into this application.

Claim Rejections - 35 USC § 102

The following is a quotation of the appropriate paragraphs of 35 U.S.C. 102 that form the basis for the rejections under this section made in this Office action:

A person shall be entitled to a patent unless -

(e) the invention was described in (1) an application for patent, published under section 122(b), by another filed in the United States before the invention by the applicant for patent or (2) a patent granted on an application for patent by another filed in the United States before the invention by the applicant for patent, except that an international application filed under the treaty defined in section 351(a) shall have the effects for purposes of this subsection of an application filed in the United States only if the international application designated the United States and was published under Article 21(2) of such treaty in the English language.

Claims 1, 6, 8-9,14 and 16 are rejected under 35 U.S.C. 102(e) as being anticipated by Dayal et al. (7,046,352).

As regard to claim 1, Dayal discloses a pattern inspection apparatus to inspect defects of a substrate comprising of the following:

an illumination optics (103/107/108/109) which applies a first inspection light of a predetermined wavelength to a surface opposite to a pattern formed surface of the substrate (110), and applies a second inspection light whose wavelength equal the predetermined wavelength of the first inspection light to the pattern formed surface (fig. 1), a detector (D) which selectively detects a transmitted light through the substrate by irradiation of the first inspection light and a reflected light from the substrate by irradiation of the second inspection light so as to perform a transmitted-light-based inspection and a reflected-light-based inspection (col. 4, line 59-col. 5, line 1-3) and a space separation mechanism (107/relative position of reflected/transmitted light) which is provided in the vicinity of an optical focal plane toward the pattern formed surface of the substrate, and spatially separates an irradiation area of the first inspection light and the second inspection light such that the transmitted light (106) through the

substrate and the reflected light (104) from the substrate are imaged in two discrete areas separated on the optical focal plane (fig. 1).

As to claims 6 and 14, Dayal discloses wherein the optical focal plane toward the pattern formed surface of the substrate at least a magnification focal plane of an observation field observed in the pattern formed surface, and a mirror (107/109) is used as the space separation mechanism, and the mirror is fixed at a position offset from the optical focal plane (fig. 1).

As to claims 8 and 16, Dayal discloses wherein the illumination optics (103/107/108/109) has a single light source (101)(fig. 1)

As regard to claim 9, Dayal discloses a pattern inspection apparatus to inspect pattern defects of a substrate comprising of the following:

a first illumination optics (103/107/108/109) which applies a first inspection light of a predetermined wavelength to a surface opposite to a pattern formed surface of the substrate,

a first detection sensor (D) which detects a transmitted light through the substrate by irradiation of the first inspection light, for a transmitted-light-based inspection, a second illumination optics (103/107/108/109) which applies a second inspection light whose wavelength is equal to the predetermined wavelength of the first inspection light to the pattern formed surface of the substrate, a second detection sensor (D) which detects a reflected light from the substrate by irradiation of the second inspection light, for a reflected-light-based inspection and a space separation mechanism (107/relative position of reflected/transmitted light) which is provided in the vicinity of an optical focal plane between the pattern formed surface of the substrate (110) and the first detection sensor and the second detection sensor, and separates the transmitted light and the reflected light from the substrate such that the transmitted light through the substrate and the reflected light are imaged in two discrete areas separated on the optical focal plane (fig. 1)(col. 4, line 52-col. 5, line 1-18).

Claim Rejections - 35 USC § 103

The following is a quotation of 35 U.S.C. 103(a) which forms the basis for all obviousness rejections set forth in this Office action:

(a) A patent may not be obtained though the invention is not identically disclosed or described as set forth in section 102 of this title, if the differences between the subject matter sought to be patented and the prior art are such that the subject matter as a whole would have been obvious at the time the invention was made to a person having ordinary skill in the art to which said subject matter pertains. Patentability shall not be negatived by the manner in which the invention was made.

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Claims 2 and 10 are rejected under 35 U.S.C. 103(a) as being unpatentable over Dayal et al. (7,046,352) in view of Murakami et al. (5,017,798)

Claims 2 and 10 are rejected under 35 U.S.C. 103(a) as being unpatentable over Dayal in view of Murakami, as applied to claims 1 and 9. The reference of Dayal teaches of the features of claim 1, comprising detection optics (103/107/108/109)(fig. 1), however the reference of Dayal is silent regarding a first detection optics and a second detection optics. The reference of Murakami teaches of a first detection optics and a second detection optics (7a/7b)(figs. 3 and 5)(col. 5, line 30-39). It would have been obvious to one having ordinary skill in the art at the time of invention to provide a first detection optics which leads the transmitted light separated by the space separation mechanism to the detector and a second detection optics which leads the reflected light separated by the space separation mechanism to the detector for the purpose of using multiple devices to detect reflected light and transmitted light simultaneously with accuracy.

Claims 3 and 11 are rejected under 35 U.S.C. 103(a) as being unpatentable over Dayal et al. (7,046,352) in view of Murakami et al. (5,017,798) and further in view of Nikoonahad et al. (6,919,957 B2)

Claims 3 and 11 are rejected under 35 U.S.C. 103(a) as being unpatentable over Dayal in view of Murakami and further in view of Nikoonahad, as applied to claims 2 and 10 above. The reference of Dayal and Murakami teaches of the features of claim 2. The reference of Dayal is silent regarding the use of the first detection optics and the second detection optics to change a magnification for an observed image and change an illumination area of the illumination optics in accordance with the magnification thereof. The use of detection optics to change a magnification for an observed image is known as evident by Nikoonahad et al. (col. 160, claim 86). It would have been obvious to one having ordinary skill in the art at the time of invention to provide detection optics that change a magnification for an observed image for the purpose of detecting and determining a critical dimension of a micro defects or a macro defects on a front side of the specimen with accuracy.

Claims 7 and 15 are rejected under 35 U.S.C. 103(a) as being unpatentable over Dayal, as applied to claims 1 and 9 above. The reference of Dayal teaches of the features of claims 1 and 9, comprising supporting stage (not shown), suggested TDI sensor (fig. 1)(col. 4, line 65-67). The reference of Dayal is silent regarding an XY stage on which the substrate mounted and the type of sensor used as a detection sensor being (i.e. TDI sensor) and that number of accumulation steps of the TDI sensor for the transmitted-light-based inspection is different from that of the accumulation steps of the TDI sensor for the reflected-light-based inspection. There is no reason for the number accumulation steps of the sensor (i.e. TDI sensor) for the transmitted-light-based inspection and the accumulation steps of the sensor (i.e. TDI sensor) for the reflected-light-based inspection to be the same since they are independent of each other. The use of an XY stage on which the substrate is mounted to obtain a pattern image and a sensor (i.e. TDI sensor) is known as evident by Maeda et al. (6,556,290 B2)(fig. 3). It would have been obvious to one having ordinary skill in the art at the time of invention to provide an XY stage on which the substrate mounted and the number of accumulation steps of the TDI sensor for the transmitted-light-based inspection that is different from that of the accumulation steps of the TDI sensor for the reflected-light-based inspection for the purpose scanning, aligning and measuring with accuracy.

Allowable Subject Matter

Claims 17-21 are allowable

As to claim 17, the prior art of record, taken alone or in combination, fails to disclose or render obvious a polarizing beam splitter which is provided in the vicinity of an optical focal plane between the pattern formed surface of the substrate and the second detection sensor, and reflects or transmits the first inspection light and the second inspection light to send to the pattern formed surface of the substrate, and transmits or reflects the reflected light from the substrate to send to the second detection sensor, in combination with the rest of the limitations of the claim. Claims 18-21 are allowable by virtue of their dependency on claim 17.

Claims 4-5 and 12-13 are objected to as being dependent upon a rejected base claim, but would be allowable if rewritten in independent form including all of the limitations of the base claim and any intervening claims.

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As to claim 4, the prior art of record, taken alone or in combination, fails to disclose or render obvious illumination optics has a polarizing beam splitter provided between the pattern formed surface of the substrate and the space separation mechanism, and the polarizing beam splitter reflects the second inspection light to lead the second inspection light to the pattern formed surface of the substrate, and lets the transmitted light through the substrate and the reflected light from the substrate pass through.

As to claim 5, the prior art of record, taken alone or in combination, fails to disclose or render obvious the illumination optics has a polarizing beam splitter provided between the space separation mechanism and the detector, and the polarizing beam splitter transmits or reflects the second inspection light to lead the second inspection light to the space separation mechanism, and reflects or lets through the reflected light from the substrate obtained via the space separation mechanism to lead the reflected light to the detector

As to claim 12, the prior art of record, taken alone or in combination, fails to disclose or render obvious the second illumination optics has polarizing beam splitter provided between the pattern formed surface of the substrate and the space separation mechanism, and the polarizing beam splitter reflects the second inspection light to lead the second inspection light to the pattern formed surface of the substrate, and lets the transmitted light through the substrate and the reflected light from the substrate pass through.

As to claim 13, the prior art of record, taken alone or in combination, fails to disclose or render obvious the second illumination optics has a polarizing beam splitter provided between the space separation mechanism and the second detection sensor, and the polarizing beam splitter transmits or reflects the second inspection light to lead the second inspection light to the space separation mechanism, and reflects or lets through the reflected light from the substrate obtained via the space separation mechanism lead the reflected light to the second detection Sensor.

Additional Prior Art

The prior art made of record and not relied upon is considered pertinent to applicant's disclosure. The references listed in the attached form PTO-892 teach of other prior art pattern inspection apparatus to inspect defects of a substrate that may anticipate or obviate the claims of the applicant's invention.

Response to Arguments

Applicant's arguments/remarks, see pages 9-11, filed 30 August 2006, with respect to the rejection(s) of claim(s) 1-3, 6-8,10-11 and 14-16 and under 35 U.S.C. 102(b) and 35 U.S.C. 103(a) have been fully considered and are persuasive. Therefore, the rejection has been withdrawn. However, upon further consideration, a new ground(s) of rejection is made in view of claim amendment.

Conclusion

Applicant's amendment necessitated the new ground(s) of rejection presented in this Office action. Accordingly, **THIS ACTION IS MADE FINAL**. See MPEP § 706.07(a). Applicant is reminded of the extension of time policy as set forth in 37 CFR 1.136(a).

A shortened statutory period for reply to this final action is set to expire THREE MONTHS from the mailing date of this action. In the event a first reply is filed within TWO MONTHS of the mailing date of this final action and the advisory action is not mailed until after the end of the THREE-MONTH shortened statutory period, then the shortened statutory period will expire on the date the advisory action is mailed, and any extension fee pursuant to 37 CFR 1.136(a) will be calculated from the mailing date of the advisory action. In no event, however, will the statutory period for reply expire later than SIX MONTHS from the date of this final action.

Fax/Telephone Information

Any inquiry concerning this communication or earlier communications from the examiner should be directed to Isiaka Akanbi whose telephone number is (571) 272-8658. The examiner can normally be reached on 8:00 a.m. - 4:30 p.m.

If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, Gregory J. Toatley Jr. can be reached on (571) 272-2059. The fax phone number for the organization where this application or proceeding is assigned is 703-872-9306.

Information regarding the status of an application may be obtained from the Patent Application Information Retrieval (PAIR) system. Status information for published applications may be obtained from either Private PAIR or Public PAIR. Status information for unpublished applications is available through Private PAIR only. For more information about the PAIR system, see http://pair-direct.uspto.gov. Should you have questions on access to the Private PAIR system, contact the Electronic Business Center (EBC) at 866-217-9197 (toll-free).

Isiaka Akanbi
November 9, 2006

Gregory Totaley, Ir.